

Information Disclosure Statement  
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Page 3

Form PTO-1449 (Modified)	ATTY DOCKET NO. B-4265DIV of PCT 621722-3	U.S. SERIAL NO. <del>not yet assigned</del> 10/798,584
LIST OF PATENTS AND PUBLICATIONS STATEMENT	APPLICANT(S) Se-Hwan SON, et al.	
	FILING DATE <del>concurrently</del> herewith 03/10/2004	GROUP <del>2815</del> 1774

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	ISSUE DATE	NAME	CLASS	SUBCLASS	FILING DATE OF 102(e) DATE IF APPROPRIATE
MEY	4,356,429	10/1982	Tang	313	503	—
MEY	4,780,536	10/1988	Czarnik, et al.	544	225	—
MEY	5,366,811	11/1994	Higashi, et al.	428	457	—
MEY	5,540,999	7/1996	Yamamoto, et al.	428	411.1	—
MEY	5,616,427	4/1997	Tada	428	690	—
MEY	6,312,838 B1	11/2001	Ishibashi et al.	428	690	—
MEY	6,436,559 B1	8/2002	Ueno et al.	428	690	—

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES/NO
MEY	06-163158	6/1994	JP	—	—	Abstract
MEY	07-11249	1/1995	JP	—	—	Abstract

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

MEY	Kruger, Jessica, et al., "Modification of TiO <sub>2</sub> Heterojunctions with Benzoic Acid Derivatives in Hybrid Molecular Solid-State Devices," <i>Advanced Materials</i> , Vol. 12, pp. 447-51 (2000).
MEY	Kim, J.S., et al., "Indium-tin oxide treatments for single- and double-layer polymeric light-emitting diodes: The relation between the anode physical, chemical, and morphological properties and the device performance," <i>Journ. of Applied Physics</i> , Vol. 84, No. 12, pp. 6859-70 (December 15 1998).
MEY	Pieterse, Koen, et al., "Towards Organic N-Type Semi-Conducting Materials," <i>Polymer Preprint</i> , 40, pp. 404-5 (1999).

EXAMINER <i>Marie L. Garmitsky</i>	DATE CONSIDERED <i>Aug. 15, 2006</i>
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EXAMINER: Initial is reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.